

## IN THE CLAIMS

**Please amend the claims as follows:**

1. (previously presented) A photoresist composition, comprising an admixture of a phenolic resin and an onium carboxylate salt, wherein the dissolution rate of said photoresist composition in aqueous base is less than about  $1.3 \times 10^{-4}$   $\mu\text{m}/\text{sec}$ .
2. (original) The photoresist composition of claim 1, wherein the onium carboxylate is an onium cholate, onium lithocholate, or onium deoxycholate.
3. (original) The photoresist composition of claim 2, wherein the onium cholate is an iodonium cholate.
4. (original) The photoresist composition of claim 3, wherein the iodonium cholate is an alkyloxyphenylphenyl iodonium cholate.
5. (previously presented) The photoresist composition of claim 4, wherein the alkyloxyphenylphenyl iodonium cholate is octyloxyphenylphenyl iodonium cholate.
6. (original) The photoresist composition of claim 1, wherein the phenolic resin is novolac.
7. (original) The photoresist composition of claim 1, wherein the onium carboxylate is present in an amount of at least 20 wt%.
8. (original) The photoresist composition of claim 1, wherein said photoresist composition can withstand pre-exposure baking temperatures of at least 125 °C.
9. (cancelled)
10. (currently amended) A single component photoresist composition,

comprising an ~~onium~~ iodonium cation protected carboxylate polymer.

11. (original) The photoresist composition of claim 10, wherein the polymer is an acrylic/acrylic acid copolymer.

12. (original) The photoresist composition of claim 11, wherein the copolymer is a methacrylic/acrylic acid copolymer.

13. (canceled)

14. (currently amended) The photoresist composition of claim ~~43~~ 10, wherein the iodonium cation is an alkyloxyphenylphenyl iodonium cation.

15. (previously presented) The photoresist composition of claim 14, wherein the alkyloxyphenylphenyl cation is an octyloxyphenylphenyl iodonium cation.

16. (original) The photoresist composition of claim 10, wherein the onium cation is present at a concentration of at least 25 mole%.